



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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TC 1700

In re application of:

Jae Heon Park, et al.

Application No.: 09/624,712

Filed: July 25, 2000

Attorney Docket No.: 006601.P035

For: METHOD FOR AN IMPROVED
DEVELOPING PROCESS IN
WAFER PHOTOLITHOGRAPHY

Examiner: K. Duda

Art Unit: 1756

MAIL STOP NON-FEE AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, Virginia 22313-1450

AMENDMENT AND RESPONSE TO OFFICE ACTION

Sir:

In response to the Office Action mailed July 1, 2003, applicants respectfully request that the above-identified application be amended as follows.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Mail Stop Non-Fee Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450 on October 28, 2003.

Christine Donahue

(Typed or printed name of person mailing correspondence)

(Signature of person mailing correspondence)